	Туре	L#	Hits	Search Text	DBs	Time Stamp	o m m e nt	D ef in	Er ro rs
1	BRS	L1	348	etch\$3 same interconnect same ((HCl or hydrochloric) or (HF or hydrofluoric))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/01 17:52			0
2	BRS	L8	201	1 and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/01 19:52			0
3	BRS	L15	127	8 and @pd<=20000829	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/01 19:52			0
4	BRS	L29	90	(low adj (k or dielectric)) with ("fluorosilicate glass")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/01 19:52			0
5	BRS	L36	66	29 and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/01 19:52			0
6	BRS	L43	8	36 and @pd<=20000829	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/01 19:53			0